

## Clean rooms Clean laboratories

### Laboratory for trace element analysis



Bohumil Dočekal

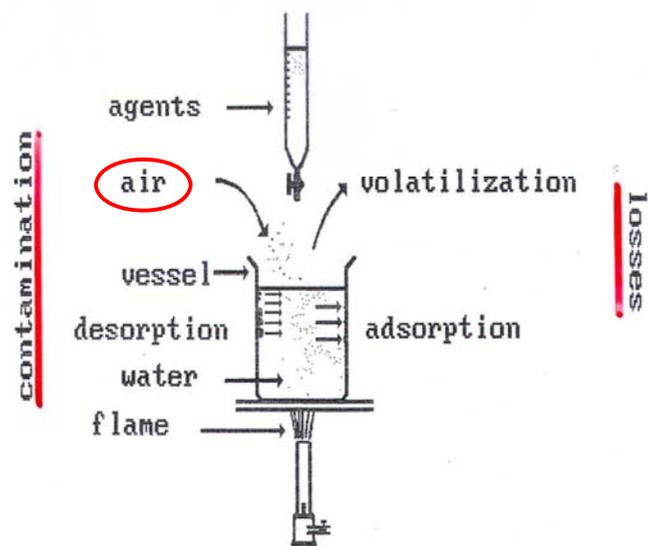
Institute of analytical chemistry of the CAS, v.v.i., Brno



## Fundamental problems of trace and ultra-trace element analysis

- major and minor components  $10^0 - 10^{-2} \%$
- trace impurities  $\approx 10^{-4} \%$  (ppm)
- ultra-trace impurities  $\leq 10^{-7} \%$  (ppb)

## Sources of contamination and analyte losses



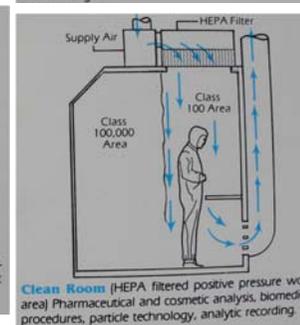
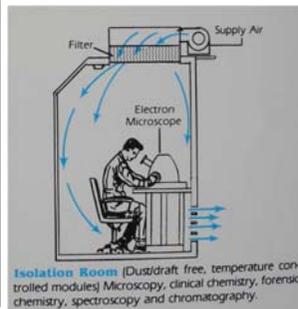
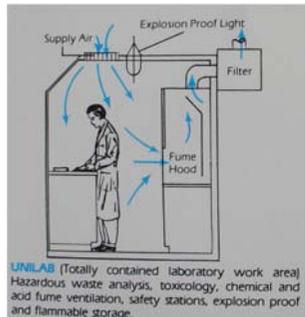
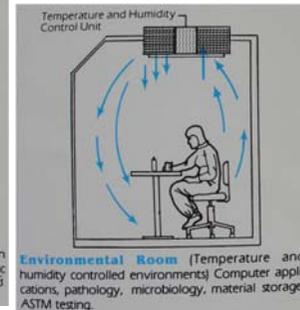
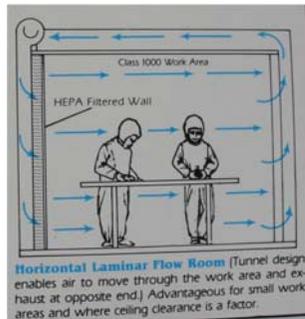
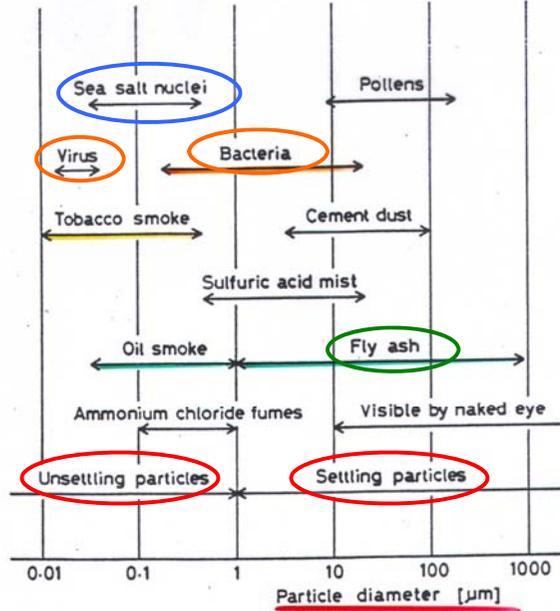
## Sources of contamination

### Abundance of elements in earth crust

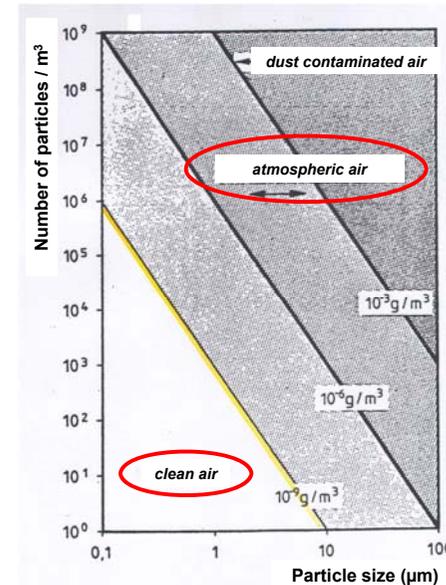
Element	%	$10^{-2}$ %	$10^{-3}$ %	$10^{-4}$ %	$10^{-5}$ %
O	46,4	Ti 57	Ni 7	Th 9	J 5
Si	28,2	H 14	Zn 7	Sm 6	Tl 4,5
Al	8,2	Mn 10	Ce 6	U 2,7	Cd 2
Fe	5,6	P 10	Co 2,5	Sn 2	Hg 1,8
Ca	4,2	S 2,6	Li 2	Ta 2	Bi 1,7
Na	2,4	C 2,0	N 2	As 1,8	Ag 0,7
Mg	2,3	Zr 1,6	Pb 1,2	Mo 1,5	Se 0,5
K	2,1	Cl 1,3	B 1	W 1	Au 0,04

R. S. Taylor, Geochim. Cosmochim. Acta 28, 1273 (1964)

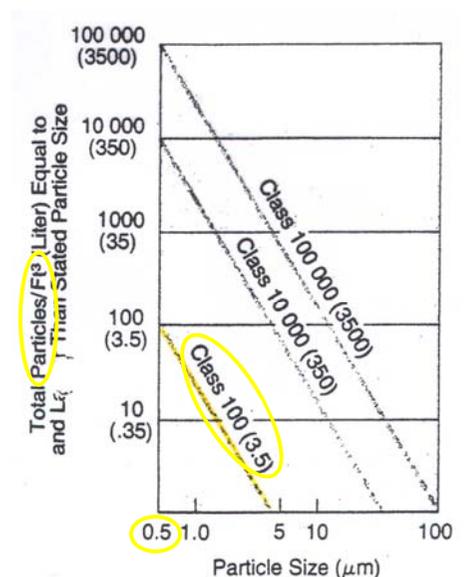
# Particle size of some types of aerosols



Relationship between the number of particles in contaminated air and their mass concentration



Limits of particle size distribution according to US Federal Standard 209b



**Classification of clean rooms according to US Federal Standard 209b and German VDI 2083**

Die Reinheitsklassen gemäss den Festlegungen des US Federal Standard 209b sowie von VDI 2083, Blatt 1.

Reinheitsklasse		maximal zulässiger Staubpegel			
US Fed. Std. 209b	VDI 2083 Bl. 1	Teilchen pro $\text{ft}^3$ Luft $> 0,5 \mu\text{m}$	Teilchen pro $\text{m}^3$ Luft $\geq 5 \mu\text{m}$	Teilchen pro $\text{m}^3$ Luft $\geq 0,5 \mu\text{m}$	Teilchen pro $\text{m}^3$ Luft $\geq 5 \mu\text{m}$
100	3	100	$< 10^*$	$4 \times 10^3$	---
1 000	4	1 000	$< 10^*$	$4 \times 10^4$	$0,03 \times 10^4$
10 000	5	10 000	70	$4 \times 10^5$	$0,03 \times 10^5$
100 000	6	100 000	700	$4 \times 10^6$	$0,03 \times 10^6$

\* aus statistischen Gründen nicht bewertet

Luwa-Vorschlag für einen erweiterten, den heutigen und den voraussehbaren Bedürfnissen der Reinraumtechnik entsprechenden US Federal Standard 209b.

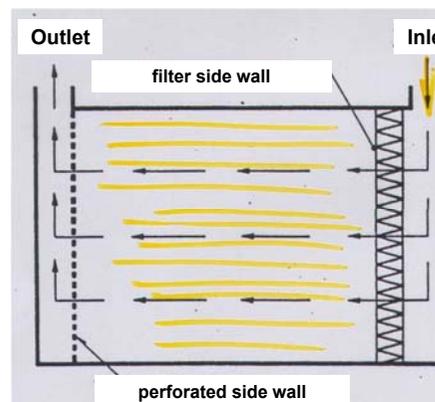
Reinheitsklasse nach		Partikel pro Kubikfuss			
VDI 2083 Blatt 1	US Fed. Std. 209b	$\geq 0,02 \mu\text{m}^*$	$\geq 0,1 \mu\text{m}$	$\geq 0,5 \mu\text{m}$	$\geq 5 \mu\text{m}$
0*	0,1*	$10^2$	$3 \times 10^0$	$10^{-1**}$	***
1*	1	$10^3$	$3 \times 10^1$	$10^0**$	***
2*	$10^*$	$10^4$	$3 \times 10^2$	$10^1$	***
3	100	****	$3 \times 10^3$	$10^2$	***
4	1 000	****	****	$10^3$	$7 \times 10^0$
5	10 000	****	****	$10^4$	$7 \times 10^1$
6	100 000	****	****	$10^5$	$7 \times 10^2$

- \* Neue Reinheits- bzw. Partikelgrößenklassen
- \*\* Angabe nur sinnvoll zum Zweck der Klassendefinition (siehe auch \*\*\*)
- \*\*\* Angabe aus statistischen Gründen für Messzwecke nicht sinnvoll
- \*\*\*\* Angabe nicht relevant für die Festlegung von Reinheitsanforderungen



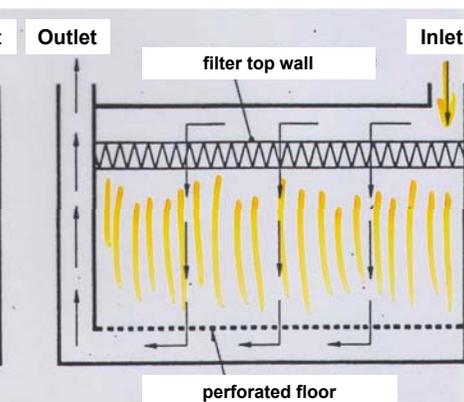
**Air flow in clean rooms**

**horizontal laminar flow**



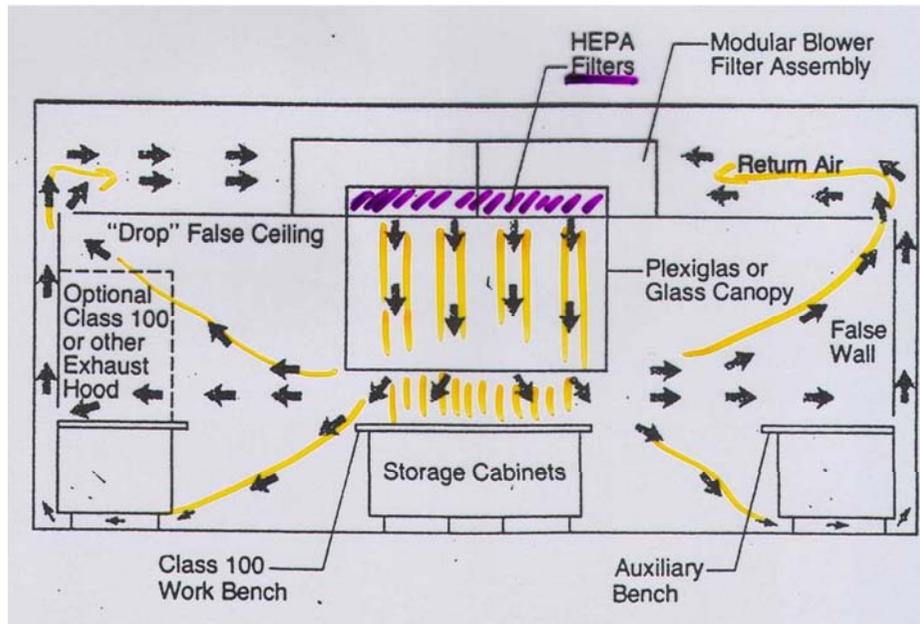
Filters are situated in the side wall, air is introduced forming air piston with horizontal laminar flow, afterwards air is returned through the perforated side wall for recirculation

**vertical laminar flow**



Filters are situated in the top wall, air is introduced forming air shower with laminar flow, afterwards air is returned through the perforated floor for recirculation

**Schematic air flow in the clean room equipped with laboratory furniture and instrumentation**

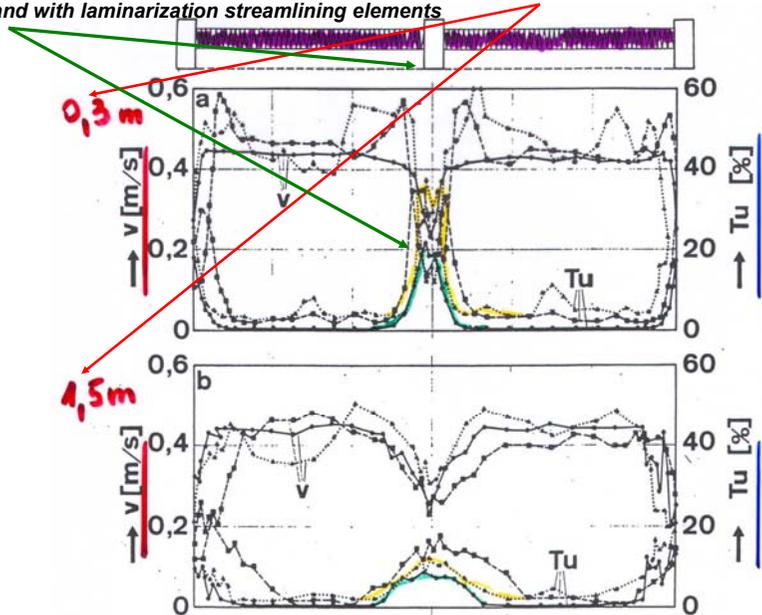


**Design - Concept of clean rooms**

- **What is the purpose / task (protection of products / samples against contamination, safety protection of personnel, eventually both approaches – in microelectronics and pharmaceutical industry, special laboratories for trace analysis and clinical biochemistry, surgical operation spaces .....**)
- **Operations (weighing, sample preparation, sample decomposition, measurement, surgery .....**)
- **Individual work places (class of cleanliness, priority of operations, GLP/GMP, assessment of contamination risk, assessment of safety hazards for personnel .....**)
- **Economy - running costs (energy consumption for heating/cooling, control of air humidity, air recirculation, removal of ballast heat from instrumentation, extraction of toxic fumes .....**)
- **Technology (air cleanliness, number of air exchanges in a room within a time period, air filtration, temperature and humidity control, minimization of ballast heat production from technological equipment, extraction hoods for dangerous fumes and gasses, space arrangement, service corridors and rooms, pressurized cabins in cascade regime)**

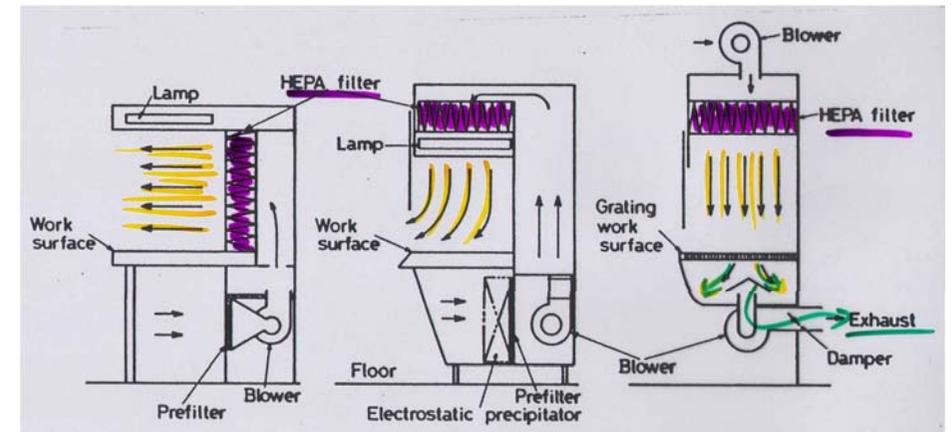
**Aerodynamic conditions in flow of streaming air**

*Linear velocity and turbulence profiles below filters in various distances from filters without and with laminarization streamlining elements*



**Laminar boxes / fume hoods (flow box, clean bench)**

*with integrated HEPA filters and hoods*



*horizontal laminar box*

*vertical laminar box without protection of personnel*

*vertical laminar box with extraction fume hood for protecting of personnel*

## Laminar boxes / hoods

BIOFUME HOOD™



vertical laminar box

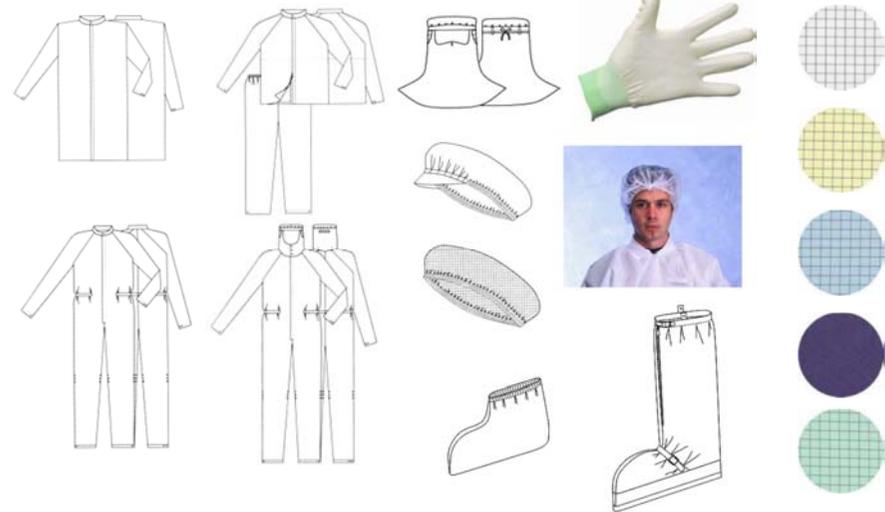


vertical laminar box with plastic curtain

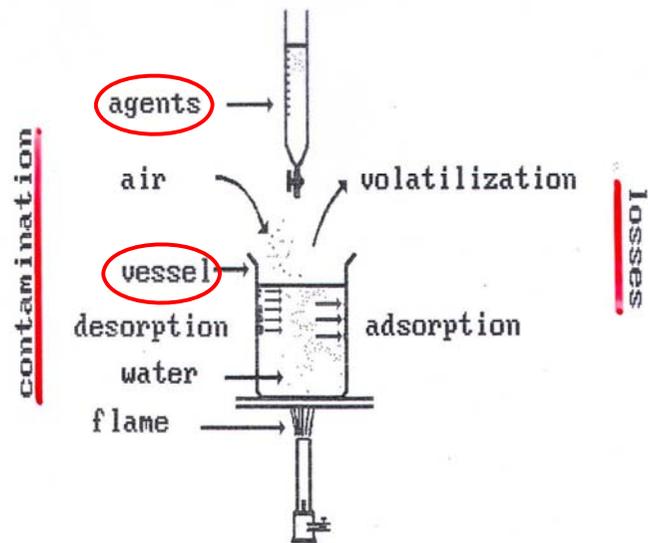
## Clothing – special clothes and protective components

**CLEANTEX®**

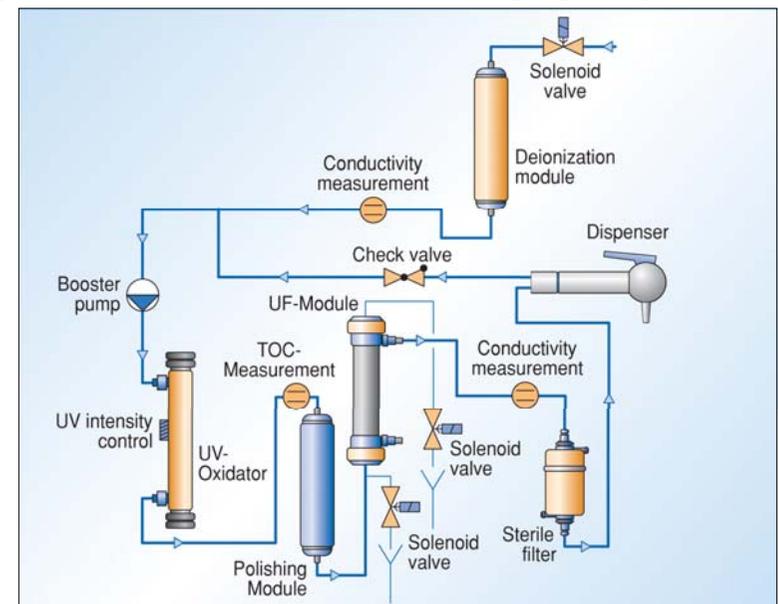
coats, overalls, two piece suits (trousers + blouse), hoods, caps, facemasks, overshoes, gloves ..... (electrostatic dissipative material)



## Sources of contamination and analyte losses



## Preparation and distribution of high purity water

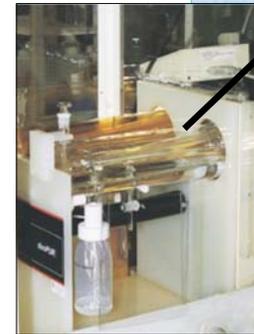
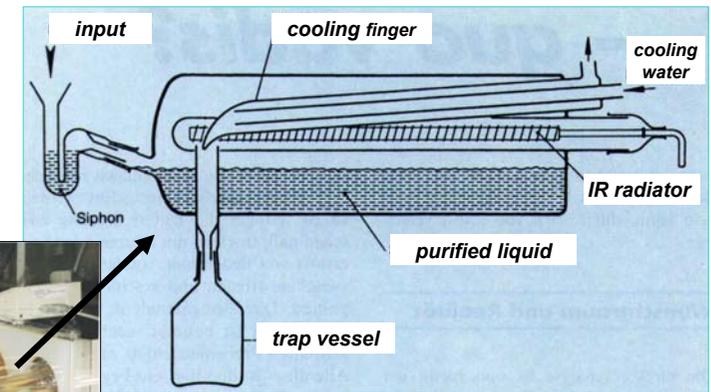


## Quality of high purity water

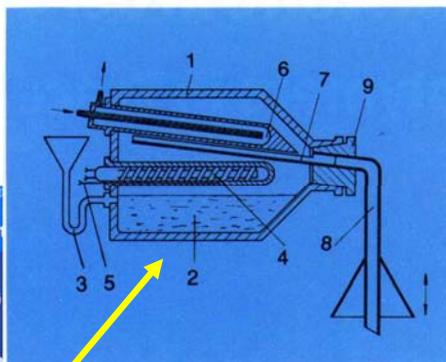


Type* Ultra Clear ...		-	UV	plus	UV plus	UV TM	UV plus TM
<b>Ultrapure water specifications</b>							
Output** up to	l/min	2	2	2	2	2	2
Conductivity at 25° C	µS/cm	0.055	0.055	0.055	0.055	0.055	0.055
Resistivity at 25° C	MΩ-cm	18.2	18.2	18.2	18.2	18.2	18.2
TOC	ppb	5-10	<1	5-10	<1	<1	<1
DNase, RNase, DNA		-	-	-	free	-	free
Bacteria	cfu/ml	<1	<1	<1	<1	<1	<1
Endotoxins	EU/ml	-	-	<0.001	<0.001	-	<0.001
Particles > 0.1 µm	per ml	<1	<1	<1	<1	<1	<1
<b>Feed water specification</b>							
Feed water pressure	bar	0.1-5	0.1-5	0.1-5	0.1-5	0.1-5	0.1-5
Feed conductivity	µS/cm	<20	<20	<20	<20	<20	<20
TOC	ppb	<50	<50	<50	<50	<50	<50

## Preparation of high purity acids and organic solvents by sub-boil distillation



## Preparation of high purity acids (HF) by sub-boil distillation



### Design

- 1 Distillation vessel out of PTFE
- 2 Fluid to be distilled
- 3 Funnel tube with siphon
- 4 Heating radiator coated with PTFE
- 5 Thermosensor
- 6 Cooling bar with water connections
- 7 Outlet channel for distillate
- 8 Outlet tubing with dust protection
- 9 Locking stopper

### Technical Data:

Volume: max. 600 ml  
 distilling performance depending on fluid and heating rate max. 20 – 40 ml/h  
 heating radiator: 0 – 300°C, 2 x 150 Watt  
 dimensions: h x w x d 320 x 450 x 180 mm

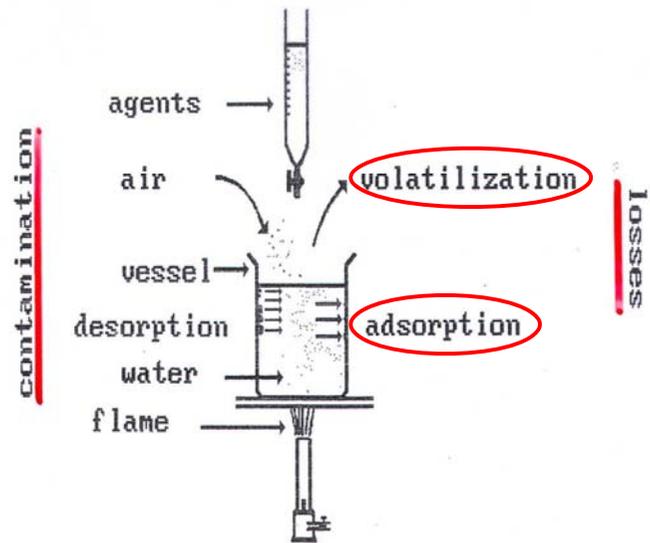
Teflon  
Fluoro Polym



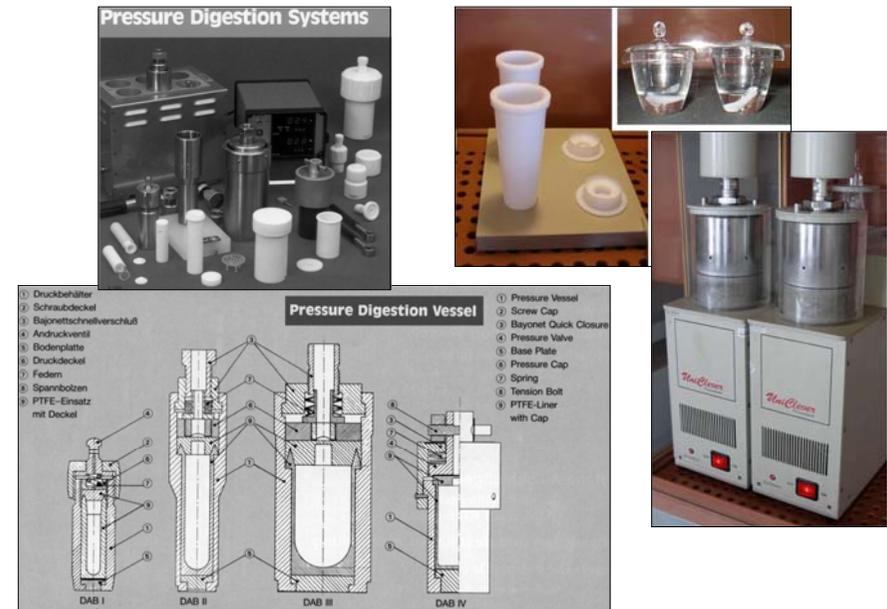
## Impurities in nitric acid (ppb)

element	acid from sub-boiling still	A.C.S. reagent grade acid	commercial high purity
Pb	0.02	0.2	0.3
Tl	—	0.2	—
Ba	0.01	8	—
Te	0.01	0.1	—
Sn	0.01	0.1	1
In	0.01	—	—
Cd	0.01	0.1	0.2
Ag	0.1	0.03	0.1
Sr	0.01	2	—
Se	0.09	0.2	—
Zn	0.04	4	8
Cu	0.04	20	4
Ni	0.05	20	3
Fe	0.3	24	55
Cr	0.05	6	130
C	0.2	30	30
K	0.2	10	11
Mg	0.1	13	—
Na	1	80	—

## Sources of contamination and analyte losses



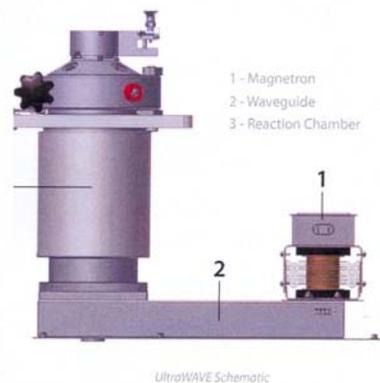
## Sample decomposition in pressurized systems



## Sample decomposition in pressurized systems

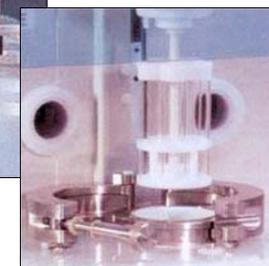
(Milestone s.r.l., Italy)

### UltraWAVE Transforming Microwave Digestion



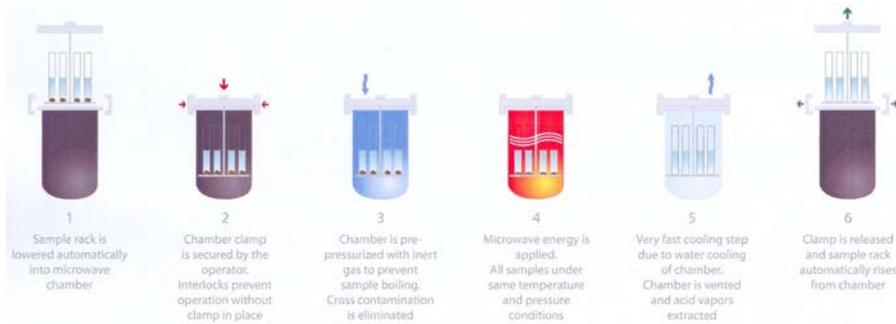
## Sample decomposition in autoclaves

(Milestone, Italy)



reaction vessel TFM/PTFE  
volume 990 ml  
magnetron power 1500 W  
max. pressure 199 bar  
max. temperature 300°C  
water cooling

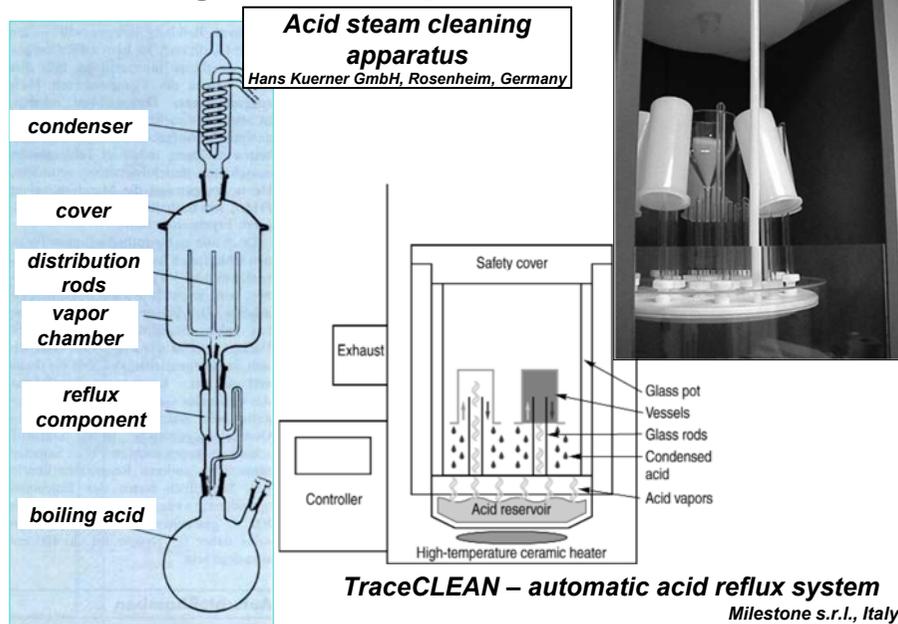
## Sample decomposition in autoclaves (Milestone, Italy)



## Materials

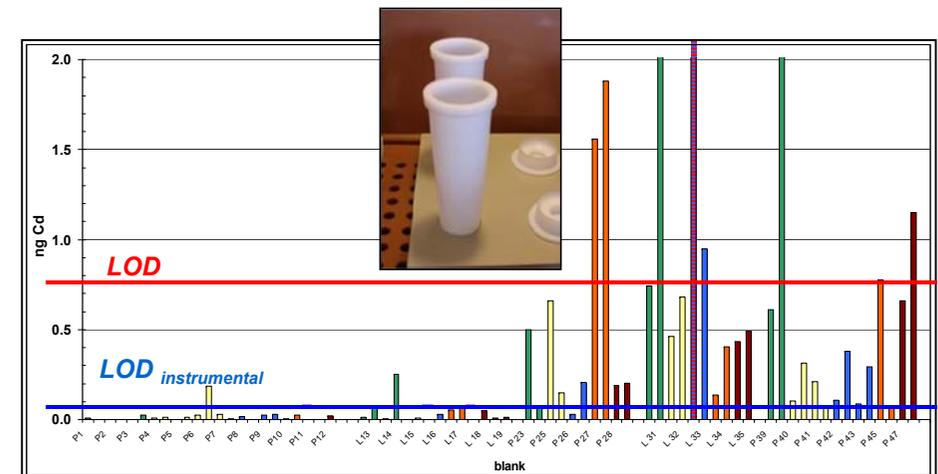
Material	Maximum service temperature (°C)	Poor chemical resistance [16] to	Permeability
Pyrex* (borosilicate glass)	600	Hydrofluoric acid, Conc. phosphoric acid, Sodium hydroxide solution	None
Vycor** (high-silica glass)	900	Hydrofluoric acid, Conc. phosphoric acid, Sodium hydroxide solution	None
Vitreous silica	1100	Hydrofluoric acid, Conc. phosphoric acid, Sodium hydroxide solution	None
Platinum	1500	Aqua regia	None
Glassy carbon [17]	600	None	None
Polyethylene	80 (High-pressure process) 110 (Low-pressure process)	Organic solvents, Conc. nitric acid, Conc. sulfuric acid	Permeable
Polypropylene	130	Organic solvents, Conc. nitric acid, Conc. phosphoric acid, Sodium hydroxide solution	Permeable
Teflon (polyfluorocarbon)	250	None	Permeable

## Cleaning of laboratory vessels

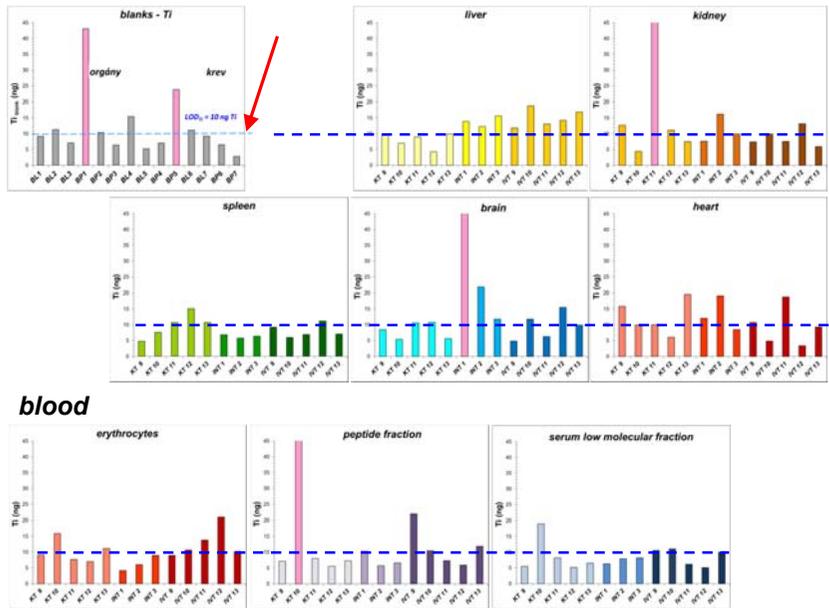


## Fluctuation of Cd blanks during microwave digestion of biological samples in closed pressurized PTFE autoclaves

- 3 ml HNO<sub>3</sub> subboiled

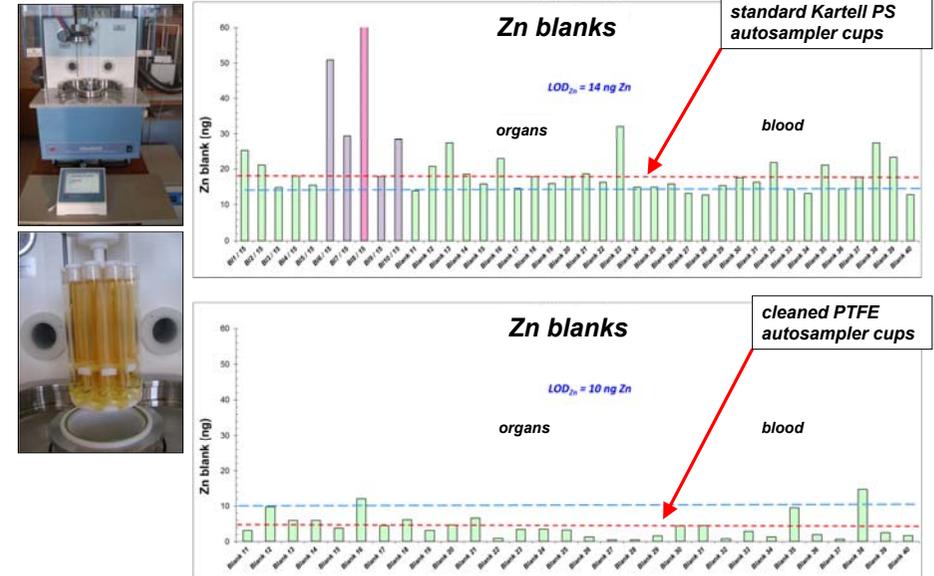


### Inhalation of TiO<sub>2</sub> nanoparticles – Analysis of mice organs

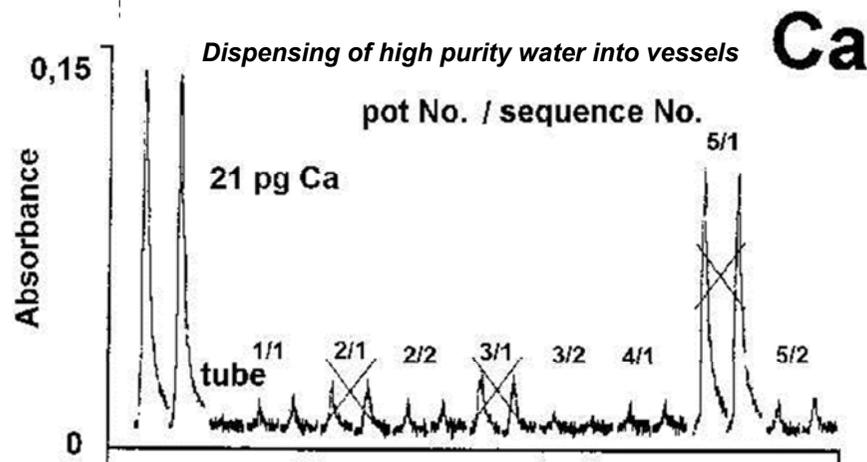


### Inhalation of ZnO nanoparticles –

Blank level and fluctuation using UltraWAVE decomposition system and TraceCLEAN acid steam cleaning



### Contamination – blanks



„Trends in Analytical Chemistry“

## Direct analysis of solid samples by electrothermal Atomic Absorption Spectrometry

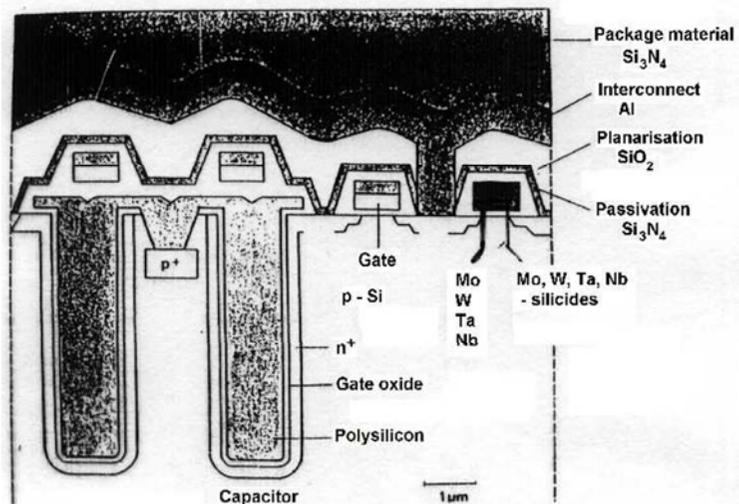
iac  
brno

Bohumil Dočekal

Ústav analytické chemie AVČR, v.v.i., Brno



## Schematic view of microelectronic cell



**Metals in VLSI-technology** (gate material)  
**6N high purity molybden (99.9999 %)**  
 (sputtering targets for plasma technology)

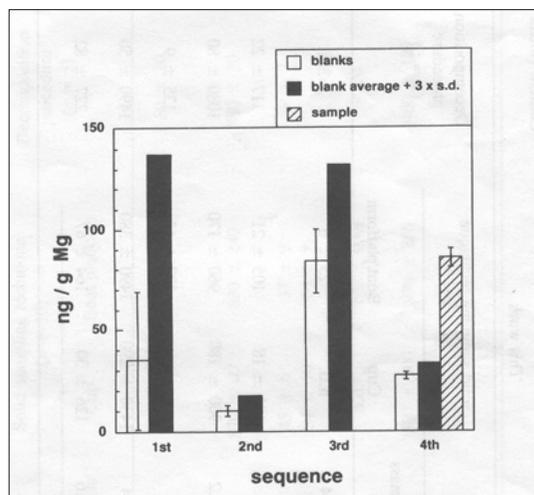
### Requested purity:

- „heavy metals“ (Cu, Fe, Mn, Ni, Pb, Zn ....) - max. 10<sup>2</sup> ppb (junction leaks)
- mobile ions (Li, Na, K, Mg, Ca ...) - max. 10<sup>1</sup> ppb (additional doping effects)
- radioactive species (U, Th ..) - below 10<sup>0</sup> ppb (ionization effects)

## Example – determination of Mg in hp Mo, hp MO<sub>3</sub>

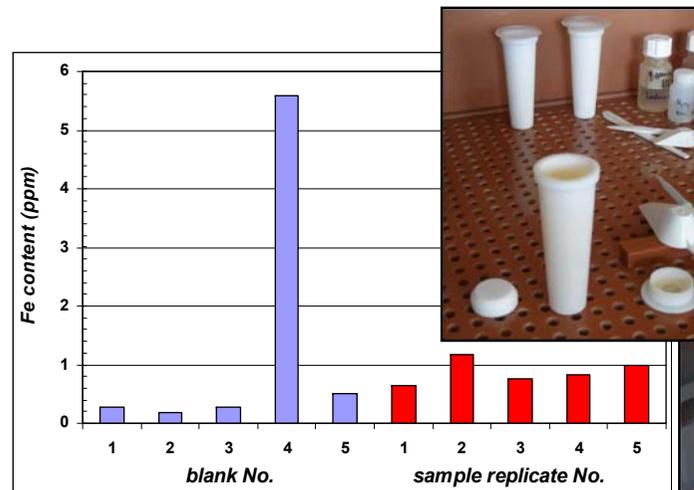
wet decomposition in HNO<sub>3</sub> + H<sub>2</sub>O<sub>2</sub> in laminar box class 100, n = 5

LODs (ppb)	
Ca	500
K	200
Mg	100
Na	200



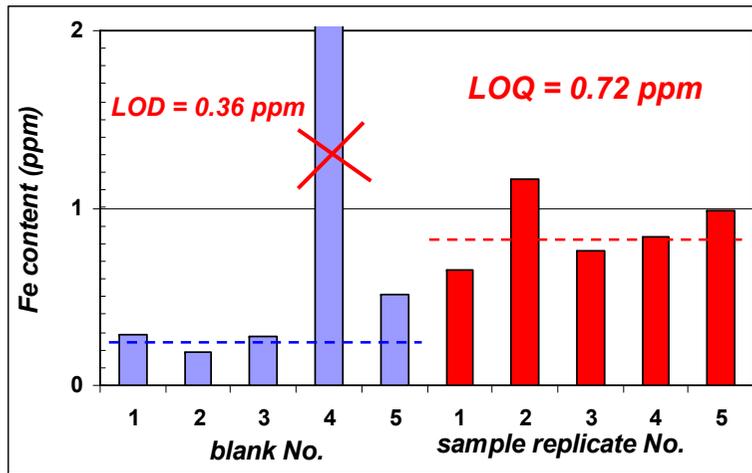
## Determination of detrimental impurities in terephthalic acid

(determination: 0.2 g sample + 3 ml conc. HNO<sub>3</sub> / 10 ml solution)



**Determination of detrimental impurities in terephthalic acid  
excluding out-layers – result  $0.56 \pm 0.22$  ppm Fe**

blank:  $0.32 \pm 0.12$  ppm      sample:  $0.88 \pm 0.18$  ppm



**Requirements on purity of  $TiO_2$**

Additive in food, pharmaceutical, cosmetic, textile technology,  
additive in cigarette paper, etc. (E175)

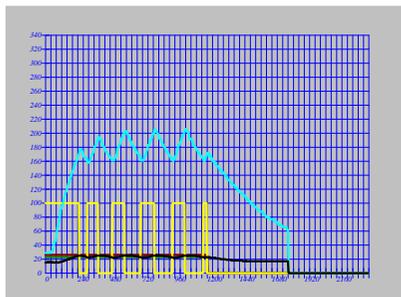
Maximální obsah stopových prvků podle Evropských norem

max. content of impurity in mg/kg (ppm)

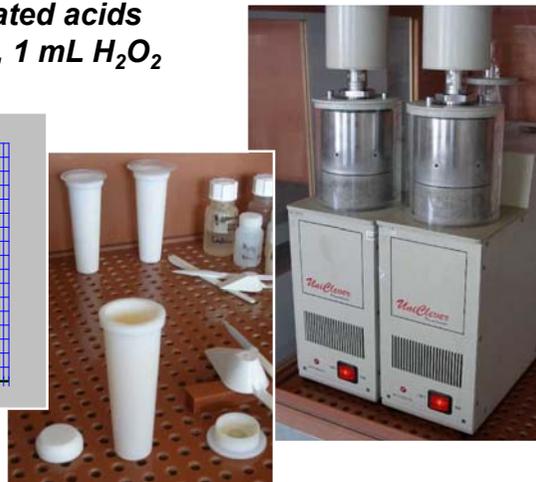
Product	As	Cd	Cr	Hg	Pb	Sb	Zn
food	3	1	20	1	10	50	50
pharma	3	0.5	10	0.5	10	50	5
paper	3	1	20	1	10	50	50
paper fine	3	1	20	1	10	50	50
fiber	3	1	20	1	10	mod. Sb <sub>2</sub> O <sub>3</sub>	50

**Sample decomposition**

0.2 g  $TiO_2$  + concentrated acids  
3 mL HF, 4 mL  $H_2SO_4$ , 1 mL  $H_2O_2$   
final volume: 10 mL



T, p, P - chart



Uniclever microwave digestion unit  
(Plazmatronika, Wrocław, Poland)  
20 min, power 100 W (max. 2.6 MPa, 250°C)

**Corrosion of graphite parts of the atomizer by  
fumes of sulphuric and hydrofluoric acids**

**Sample decomposition:**

0.2 g  $TiO_2$  + concentrated acids  
3 mL HF, 4 mL  $H_2SO_4$ , 1 mL  $H_2O_2$   
final volume: 10 mL  
sample aliquots: 10  $\mu$ L



sample boat



fumes escaping atomizer

## Spectral interference effects of sulphuric and hydrofluoric acids

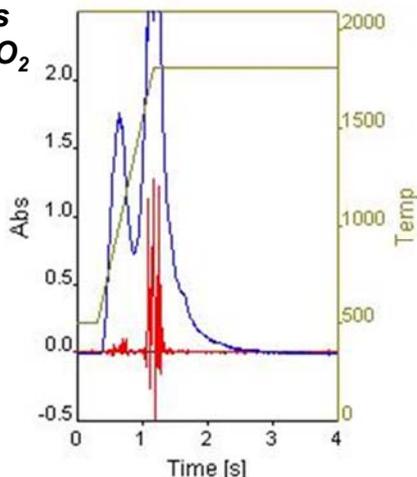
### Sample decomposition:

0.2 g TiO<sub>2</sub> + concentrated acids  
3 mL HF, 4 mL H<sub>2</sub>SO<sub>4</sub>, 1 mL H<sub>2</sub>O<sub>2</sub>  
final volume: 10 mL  
sample aliquots: 10 μL

**Sb 217.6 nm**

injected: 2.5 μL  
(LOD > 5 ppm)

similar results for  
**As 193.7 nm**  
injected: 5 μL  
(LOD = 25 ppm)



### • slurry sampling

- powdered samples
- preparation of representative suspension (1-5%)
- disintegration of agglomerates by ultra-sonication
- homogenization and stabilization of suspensions during sampling/injection of aliquots
- introduction by means of micropipettes or autosamplers

### • true direct sampling

- various types of sample carriers (miniature boats, cups, platforms)
- sample weighing
- sample introduction into the atomizer (manual, robotized)

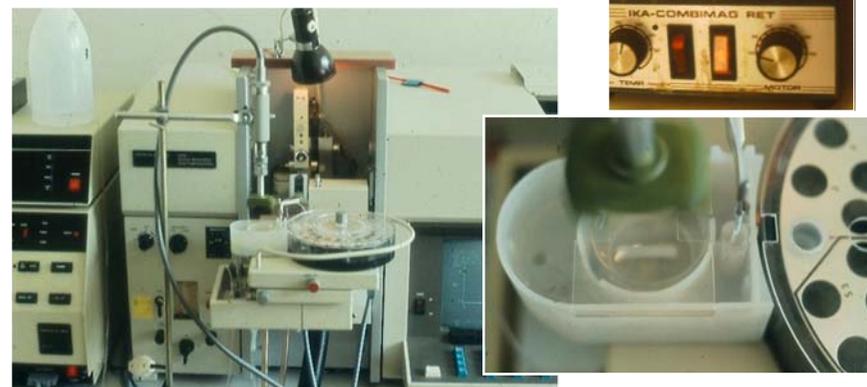
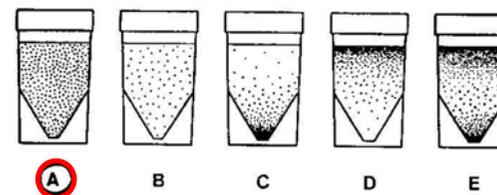
### • Slurry sampling

- measurement of real blanks in dispersion medium, control of blank level
- reduction of detection limits

Example – analysis of hp MoO<sub>3</sub>

analyte	LOD (ppb)	
	wet	slurry
Ca	500	2
K	200	1
Mg	100	0.5
Na	200	1

### homogenization and stabilization of suspensions



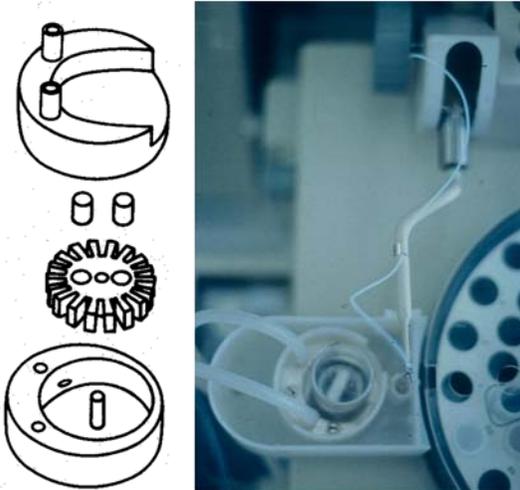
**Miniature stirring device**

turbine  
driven by air or water

magnetic rods

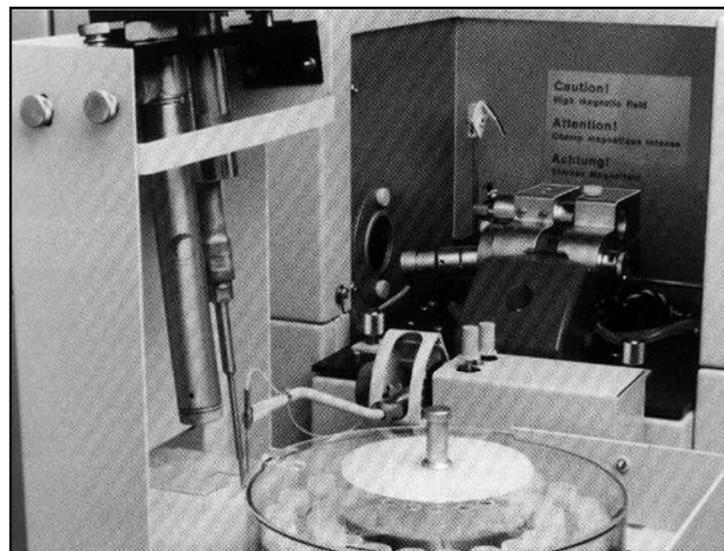


modification of the  
sample tray



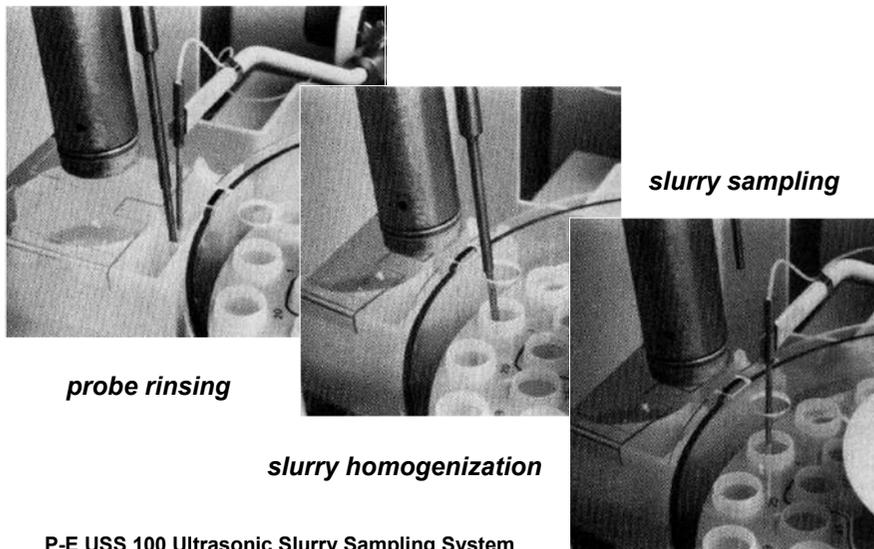
B.Dočekal, A simple stirring device for slurry sampling technique in electrothermal atomic absorption spectrometry - *J.Anal.Atom.Spectrom.*, 8, 763-764 (1993)

**Slurry homogenization by using ultrasonic probe (ultra-sonication)**



P-E USS 100 Ultrasonic Slurry Sampling System

**Ultra-sonication**



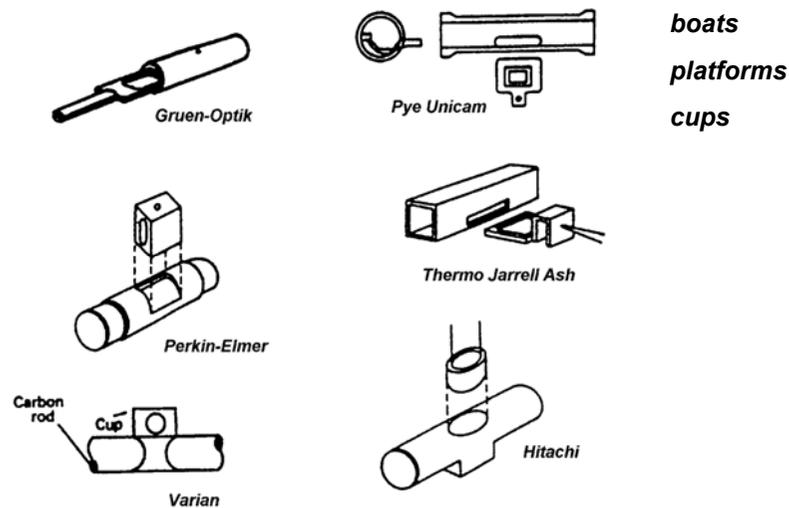
probe rinsing

slurry homogenization

slurry sampling

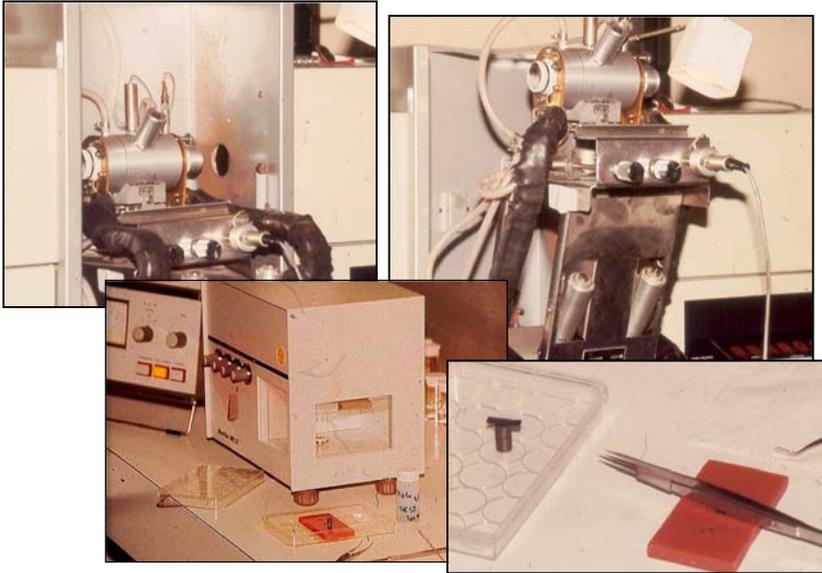
P-E USS 100 Ultrasonic Slurry Sampling System

**• Direct solid sample introduction - history**



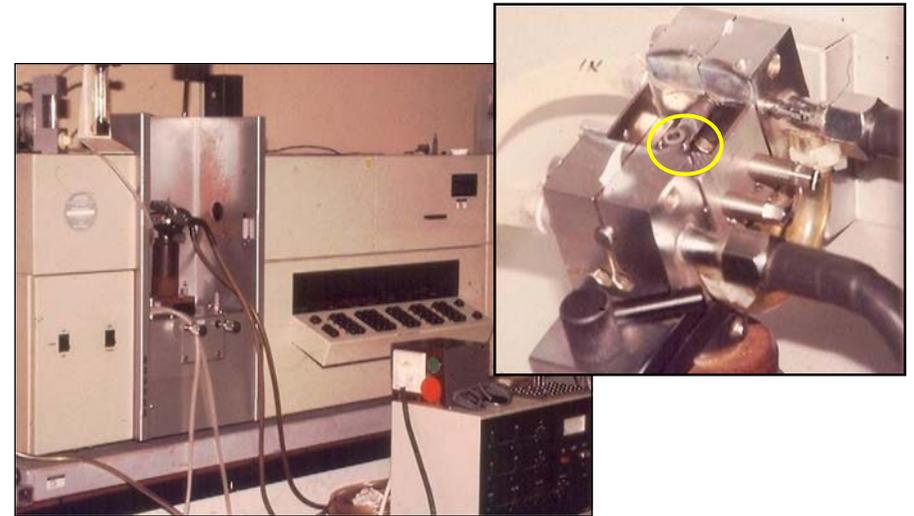
boats  
platforms  
cups

• **Direct solid sample introduction - history**



B.Docekal, V.Krivan : Determination of trace impurities in powdered molybdenum metal and molybdenum silicides by solid sampling GFAAS. - *Spectrochim. Acta* 50B, 517-526 (1995).

• **Direct solid sample introduction - history**



B.Docekal, V.Krivan : Determination of trace impurities in powdered molybdenum metal and molybdenum silicides by solid sampling GFAAS. - *Spectrochim. Acta* 50B, 517-526 (1995).

• **Direct solid sample introduction**

**3-field mode Zeeman-effect BG-correction system**



**manual solid sampling**

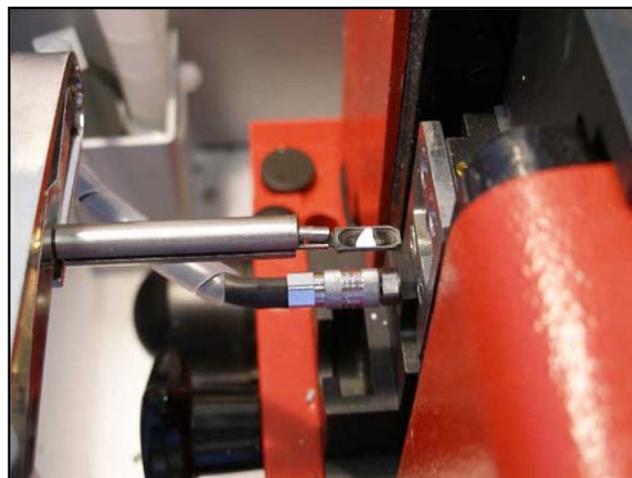


**Detail of the manual sample introduction system SSA 6 (stand-by position)**



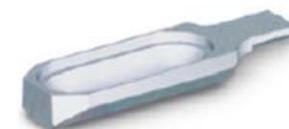
**analytikjenaAG**

*Sample in the boat*



**• Direct solid sample introduction**

**analytikjenaAG**



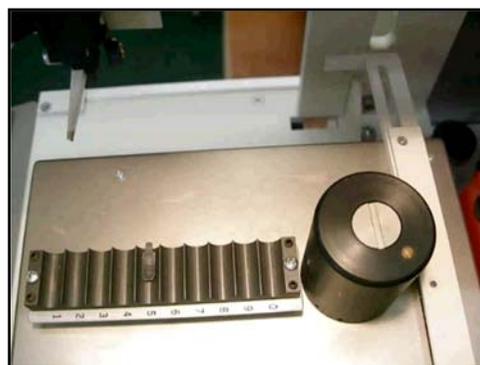
*sample carrier*

*robotic sample changer with integrated microbalance and data transmission*

*robotic sample changer with integrated microbalance and data transmission*



**analytikjenaAG**



**New robotized sample introduction system SSA 600 with integrated sampler for chemical sample modification**

**analytikjenaAG**

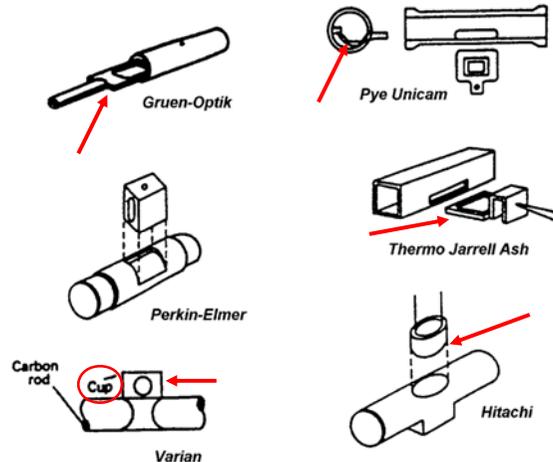


*Automatic system with 84 positions and integrated microbalance, automatic device for standard and modifier injection, integrated rinsing system*

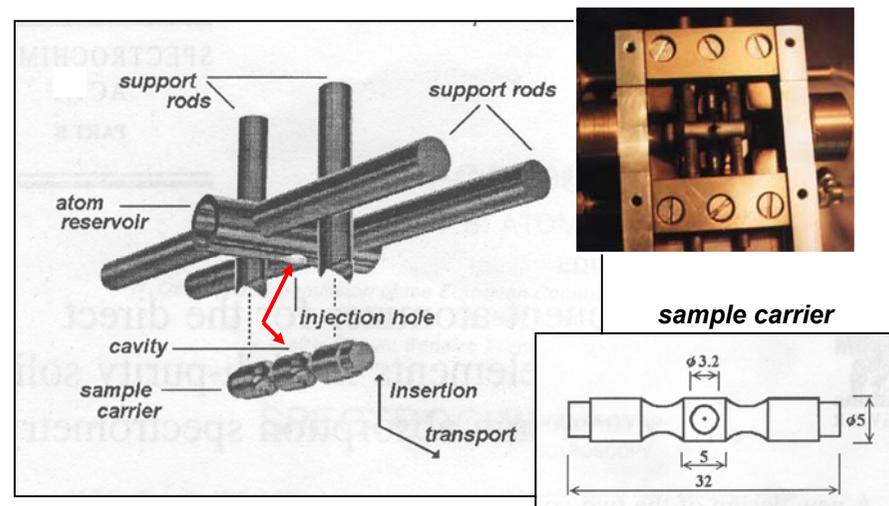
## insertion of solid samples

### How to manage blanks ?

boats  
platforms  
cups



## New design of the two-component atomizer for solid sample analysis

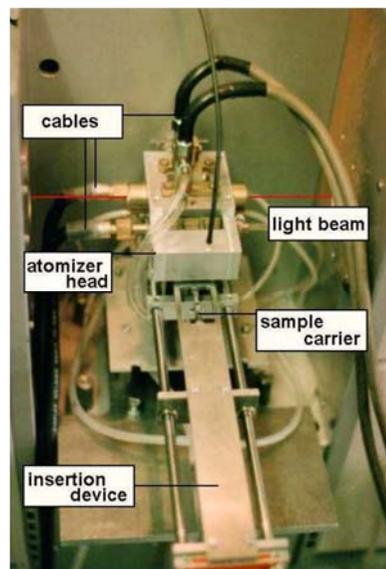


B.Docekal: A new design of the two-component atomizer for the direct determination of medium and volatile elements in high-purity solid refractory metals by electrothermal atomic absorption spectrometry. - *Spectrochim. Acta, Part B*, 53B, (1998) 427-435.

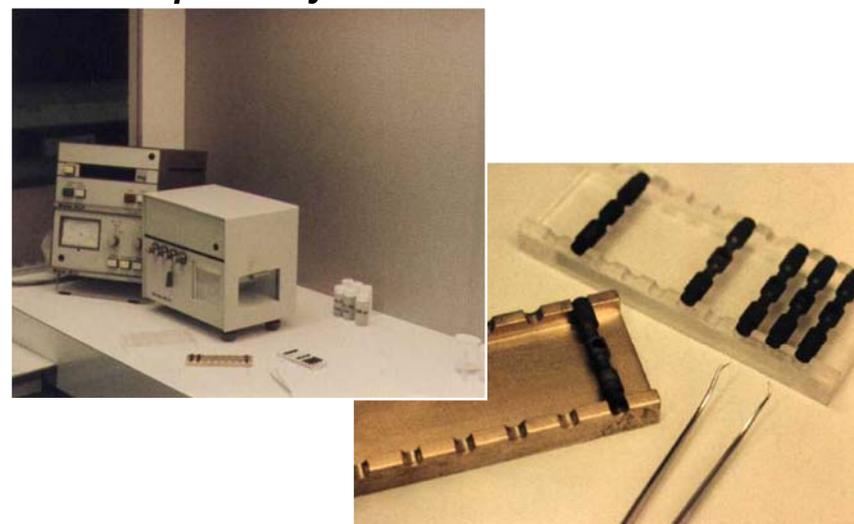
## New design of the two-component atomizer for solid sample analysis



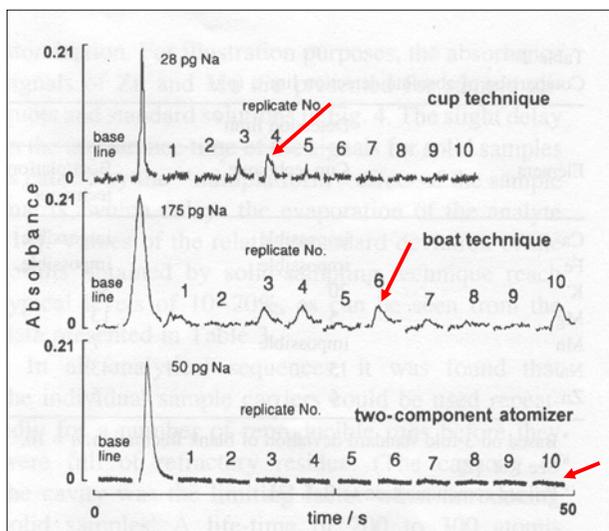
### Direct Solid Sampling AAS



## New design of the two-component atomizer for solid sample analysis



**true insertion of solid samples - contamination problems**  
**two-component versus conventional atomizers**



LODs		
Elem.	abs. (pg)	in Mo* (ppb)
Ca	13	0.3
K	3.4	0.04
Mg	0.75	0.05
Mn	12	0.15
Na	1.8	0.03
Zn	6	0.06

\* Max. sample portion of 50 mg

**“Problems” of direct solid sampling AAS ?**

**refractory matrix, “heavy” matrix (Al, Si ...)**  
**that cannot be removed during pyrolysis step or clean-out step**

**consequences:**

- build up of residue - atomizer should be cleaned, exchanged, otherwise analytical tube lifetime is significantly reduced, interference in beam path, matrix modification is less efficient
- spectral interference - high background attenuation, structured spectra of background, occurrence of systematic errors, optimization procedure is more difficult, sophisticated instrumentation is necessary to obtain reliable data (Zeeman-effect BG-correction system, HR CS AAS)



- refractory matrix
- build up of residue *TiO<sub>2</sub> samples*
- vs. clean out temperature



**high temperature treatment**

above 2000°C  
 formation of Ti-carbide phase,  
 maximum boat life time 30 runs  
 due to creeping effect of the  
 TiO<sub>2</sub>-TiC-liquid phase (m.p. 1855°C)



**low temperature treatment**

below 1900°C  
 tube and boat life time >1200 runs



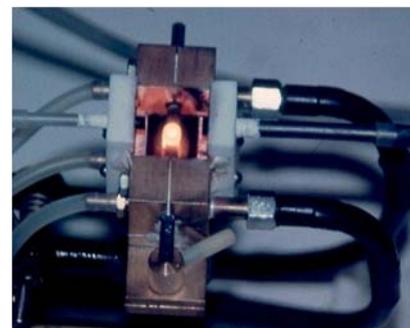
B.Dočekal, B.Vojtková: Determination of trace impurities in titanium dioxide by direct solid sampling electrothermal atomic absorption spectrometry - Spectrochim. Acta, Part B., 62 /3/ 304-308 (2007).

- refractory matrix

is it possible to vaporize/atomize the analyte from the refractory matrix ?!!  
 boiling, decomposition points are very high

**Mo - radiotracer study**

MoO<sub>3</sub> spiked with tracers reduced in hydrogen atmosphere  
 some of the analytes are excluded from the crystal lattice to the surface and can be subsequently atomized



**Percentage of residual analyte**

temp.°C	%	analytes
2100	< 2	Na, K, Cu
2300	< 5	Rb, Cs, Zn
2500	<10	Sr
2700	<10	Ba
	>10	As,Co,Cr,Fe,Ni

B.Dočekal, V.Krivan : Determination of trace impurities in powdered molybdenum metal and molybdenum silicides by solid sampling GFAAS. - Spectrochim. Acta 50B, 517-526 (1995).

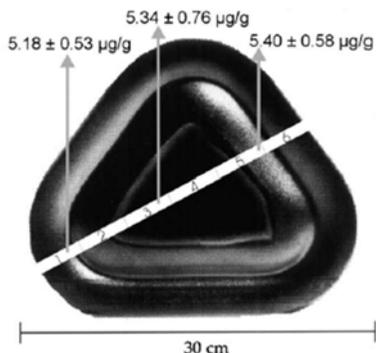
- **refractory matrix**  
**is it possible to analyze compact pieces of the refractory matrix ?!!**

*Interaction of the sample with additives (graphite .....*)

**Example**

**titanium - sputtering target**

sample is cut, etched, mixed with C,  
titanium reacts during atomization  
step exothermally with graphite  
forming carbide,  
analytes are released and measured

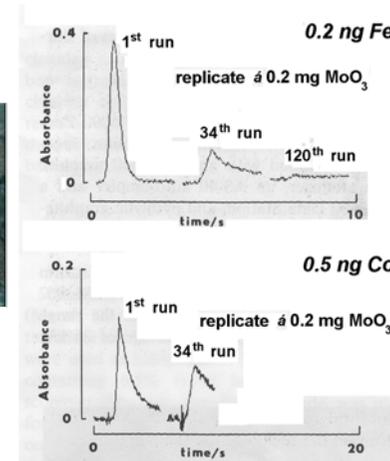
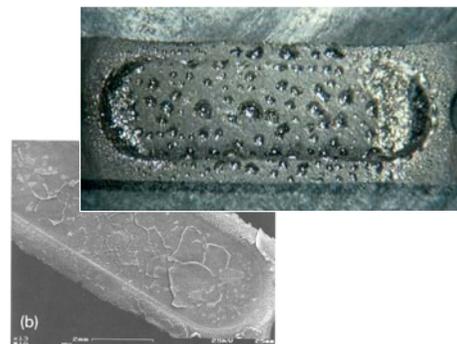


H.M.Dong, V.Krivan : A solid sampling electrothermal atomic absorption spectrometry method for direct determination of silicon in titanium pieces - *J.Anal.Atom.Spectrom.* 18, 367-371 (2003).

- **refractory matrix**  
**build up of residue - atomizer should be cleaned, exchanged, otherwise analytical tube lifetime is significantly reduced, interference in beam path**

**Example**

120 replicates,  $\bar{x}$  0.2 mg MoO<sub>3</sub>

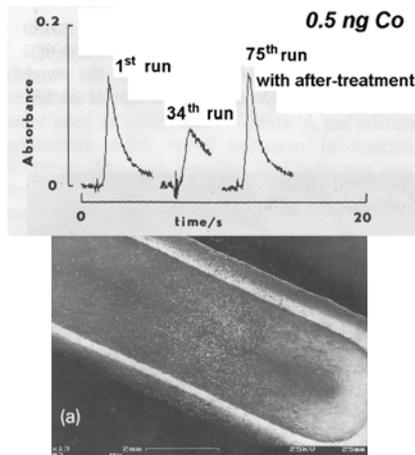


B.Docekal, V.Krivan: Halogen assisted cleaning after-treatment in graphite furnace a.a.s. for analysis of molybdenum based materials. - *Anal.Chim.Acta* 279, 253-260 (1993)

- **refractory matrix**  
**removal of matrix - atomizer should be cleaned / boat changed**  
**Freone - assisted after-treatment - volatilization of matrix residue**  
**chemical modification in gaseous phase**

**Furnace & gas program**

step	gas composition
drying	argon
pyrolysis	argon + hydrogen
atomization	argon + hydrogen
cool-down	argon
after-treatment	
at specific temperature	argon + Freone (CCl <sub>4</sub> , CF <sub>4</sub> , ...)
blow-out	argon + hydrogen
clean-out	argon
cool-down	argon



B.Docekal, V.Krivan: Halogen assisted cleaning after-treatment in graphite furnace a.a.s. for analysis of molybdenum based materials. - *Anal.Chim.Acta* 279, 253-260 (1993)

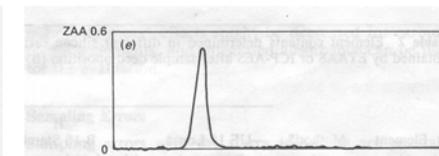
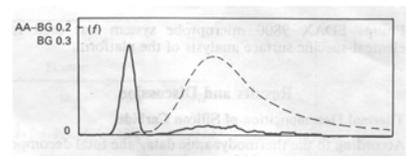
- **spectral interference**

Zn 213.8 nm

0.5 mg SiC matrix

D<sub>2</sub>-compensation system

Zeeman-effect compensation system

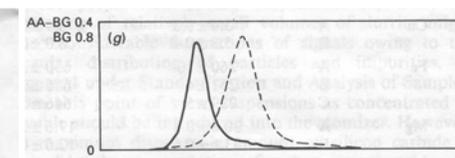
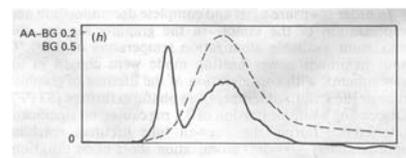


Fe 252.7 nm

0.1 mg SiC matrix

Fe 248.3 nm

D<sub>2</sub>-compensation system



## SSA 600 assisted insertion of solids & HR CS AAS

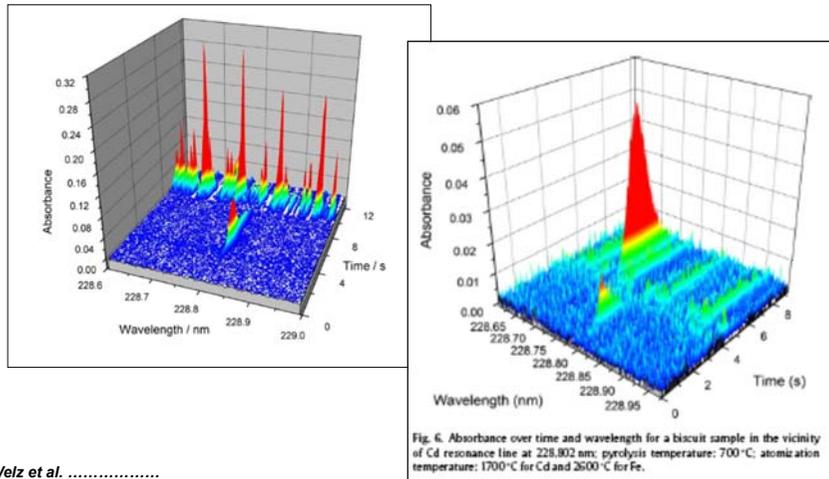


Fig. 6. Absorbance over time and wavelength for a biscuit sample in the vicinity of Cd resonance line at 228.802 nm; pyrolysis temperature: 700°C; atomization temperature: 1700°C for Cd and 2500°C for Fe.

B. Welz et al. ....

Lisia M.G. dos Santos, Rennan G.O. Araujo, Bernhard Welz, Silvana do C. Jacob, Maria Goreti R. Vale, Helmut Becker-Ross: *Talanta* 78 (2009) 577–583

## “Problems” of direct solid sampling AAS ?

- **calibration**  
lack of standards, RMs, CRMs, preparation of standards is complicated or even impossible

consequences:

- occurrence of systematic errors

- **homogeneity of the sample**  
lack of information about the homogeneity (distribution of the impurities in the sample), what portion of the sample is representative for the reality

consequences:

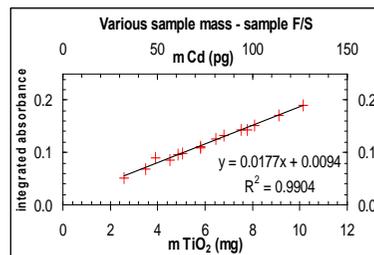
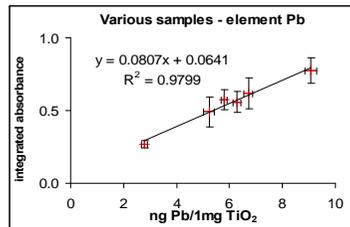
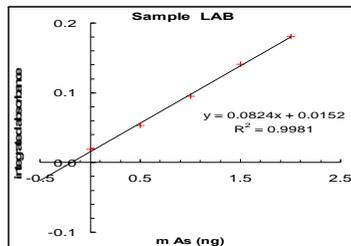
- bad reproducibility, occurrence of systematic errors

## Calibration

TiO<sub>2</sub> samples

method of internal laboratory reference samples

standard addition method

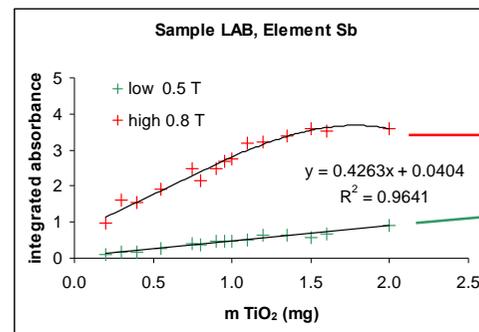


## Calibration

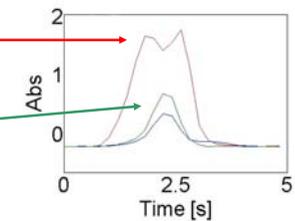
Zeeman effect 3-field dynamic mode

high value 0.8 T  
low value 0.5 T

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TiO<sub>2</sub> LAB 1.4 mg

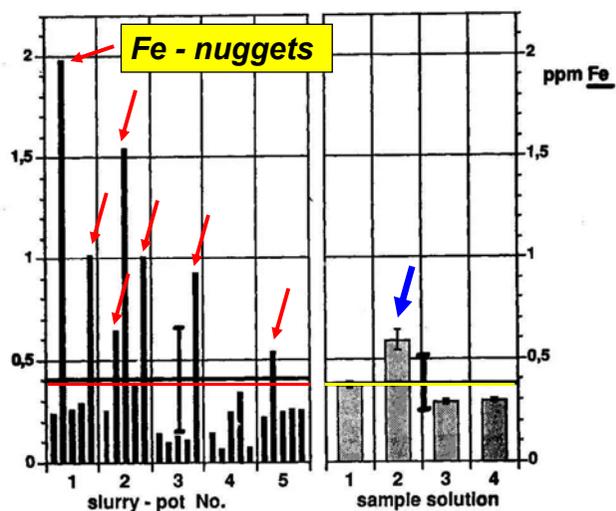


• **homogeneity – „fractionation“ study**

**aliquots**

**slurry –**  
0.2 mg MoO<sub>3</sub>

**dissolution –**  
0.5 g MoO<sub>3</sub>



B.Dočekal, V.Krivan: Determination of trace elements in high purity molybdenum trioxide by slurry sampling ET AAS. - *J.Anal.Atom.Spectrom.* 8, 637-641 (1993).

**iac**  
**brno**

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